

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In Re Patent Application of:	:		
Ravikumar Ramachandran, <i>et al.</i>	:		
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Conf. No.: 4256	:	Group Art Unit:	2822
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Appln. No.: 10/710,257	:	Examiner:	Khanh B. Duong
	:		
Filing Date: June 29, 2004	:	Attorney Docket No.:	FIS920040102US1
Title:		METHOD OF FORMING SIDEWALL SPACER USING DUAL-FREQUENCY PLASMA ENHANCED CVD	

AMENDMENT

The following Amendment is submitted in response to the non-final Office Action dated June 30, 2006 in the above-identified patent application. This amendment is being filed within the three-month statutory period set for a response. Please amend the above-identified U.S. patent application, without prejudice, as follows. A Declaration of the inventors under CFR §1.131 is being filed herewith. No fee is believed to be due in connection with filing of this paper. However, if any such fee is due, please charge such fee to deposit account No. 09-0458.

Amendments to and Listing of the Claims begin on page 2 of this paper.

Remarks begin on page 6 of this paper.